

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of:	LEE, S., et al.	Confirmation No.:	2947
Serial No.:	10/525,122	Art Unit:	2812
Filed:	March 20, 2006	Examiner:	ROMAN, A.
For:	<i>Atomic Layer Deposition of High-K Metal Silicates</i>	Attorney Docket No:	67538-5171-US

PETITION FOR EXTENSION OF TIME UNDER 37 CFR § 1.136(a)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

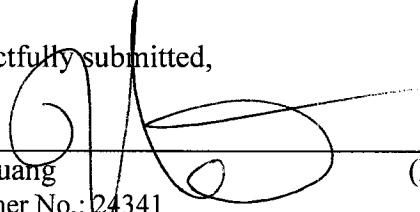
Dear Commissioner:

It is respectfully requested that the time for response to the Office Action dated July 09, 2008, be extended for a period of three-month from October 9, 2008, to January 9, 2009.

The fee for this extension is estimated to be \$1110.00. Please charge the required fee to Morgan, Lewis & Bockius LLP Deposit Account No. 50-0310 (order no. 067538-5171-US).

Date: January 9, 2009

Respectfully submitted,


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